

Supplementary information

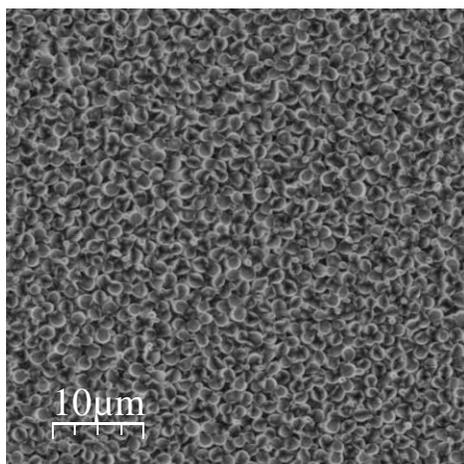


Figure 1 AFM image of phe-phe spin casted at mica surface. 10mg/ml phe-phe in HFIP

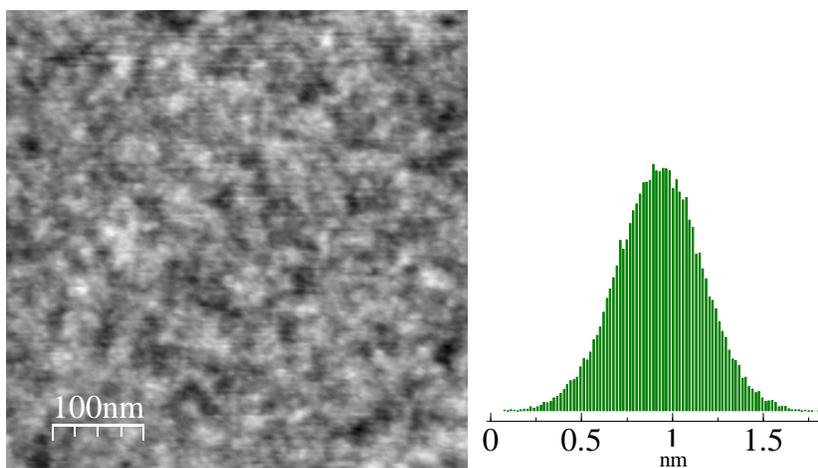


Figure 2 Height image of standard Si-wafer and roughness distribution.